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TI Metal plating of electric conducting copper or copper alloy wire for coil feeding and solderability

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AB The wire is electroplated with Ni and then with Ag or Cu at 0.5-0.2d and 5-1.5 .mu.m (d is outer diam. of the wire), resp., for easy coil feeding and good solderability. The electroplated wire shows solder-wetting time 0.1-0.5 s, wire core-melting time 5-25 s, elec. cond. (IACS) 83-100%, and tensile strength 50-85 kg/mm2.